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PATENT
Customer No. 22,852
Attorney Docket No. 02887.0269-00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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|-------------------------------|---|--------------------------|
| In re Application of: |) | |
| Katsuhiko HIEDA et al. |) | |
| |) | |
| Application No.: 10/804,159 |) | Group Art Unit: 2818 |
| |) | |
| Filed: March 19, 2004 |) | Examiner: Mai Huong TRAN |
| |) | |
| For: SEMICONDUCTOR DEVICE AND |) | Confirmation No.: 7405 |
| METHOD OF FABRICATING THE |) | |
| SAME |) | |

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

RESPONSE TO RESTRICTION REQUIREMENT

In a restriction requirement mailed on June 22, 2005, the Examiner required
restriction under 35 U.S.C. § 121 between

Group I: Claims 11, 15, 16, and 19, characterized by the Examiner
as drawn to a semiconductor device and classified in class 257, subclass
374; and

Group II: Claims 1-10, 12-14, 17-18, and 20, characterized by the
Examiner as drawn to a process of making a semiconductor device and
classified in class 438, subclass 207.

Applicants elect to prosecute Group II, claims 1-10, 12-14, 17, 18, and 20,
without traverse.

Please grant any extensions of time required to enter this response and charge any additional required fees to our Deposit Account No. 06-0916.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW,
GARRETT & DUNNER, L.L.P.

Dated: July 20, 2005

By: _____



Reece Nienstadt
Reg. No. 52,072

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